

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re U.S. Patent Application of )  
SATO et al. )  
Application Number: To be Assigned )  
Filed: Concurrently Herewith )  
For: METHOD OF MANUFACTURING AN ACTIVE )  
MATRIX SUBSTRATE AND AN IMAGE DISPLAY )  
DEVICE USING THE SAME )  
ATTORNEY DOCKET NO. HITA.0458 )

Honorable Assistant Commissioner  
for Patents  
Washington, D.C. 20231

**INFORMATION DISCLOSURE STATEMENT**

Pursuant to 37 C.F.R. §§ 1.56 and 1.97, this Information Disclosure Statement is submitted in the above-identified patent application. A listing of documents to be published on the face of any patent granted from this application is submitted herewith on Form PTO-1449. Any other documents or information submitted for consideration by the Examiner are listed in this paper. A copy of each U.S. and foreign patent, or each publication or portion thereof listed or herein identified, is submitted herewith.

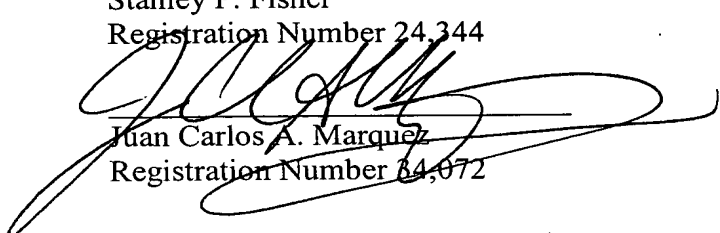
This Information Disclosure Statement is submitted with the initial filing of the application. Accordingly, no fee is due or payable at this time.

The Examiner is requested to acknowledge consideration of the information provided in this paper in accordance with prescribed procedures.

Please charge any additional fees or credit any overpayments in connection with this paper to Deposit Account No. 08-1480.

Respectfully submitted,

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Form PTO 1449  U.S. Department of Commerce Patent and Trademark Office  Information Disclosure Statement by Applicant	ATTY. DOCKET NUMBER <b>HITA-0458</b>	SERIAL NUMBER <b>To be assigned</b>
	APPLICANT <b>SATO et al</b>	
	FILING DATE <b>Concurrently herewith</b>	GROUP

**U.S. Patent Documents**

Examiner Initial		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE

**Foreign Patent Documents**

Examiner Initial		DOCUMENT NUMBER	FILING DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION	
							YES	NO
		6-140323	10/23/92	Japan			Abstract	X
		2001-274088	5/28/96	Japan			Abstract	X
		2002-280302	3/16/2001	Japan			Abstract	X

**Other Documents (Including Author, Title, Date Pertinent Pages, Etc.)**

		Chang-ho Oh and Masakiyo Matsumura, "Preparation of Position-Controlled Crystal-Silicon Island Arrays by Means of Excimer-Laser Annealing", Jpn. J. Appl. Phys., Vol. 37 (1998) pp. 5474-5479
		Do-Hyun Choi, Kazuhiro Shimizu, Osamu Sugiura and Masakiyo Matsumura, "Drastic Enlargement of Grain Size of Excimer-Laser-Crystallized Polysilicon Films", Jpn. J. Appl. Phys., Vol. 31 (1992) pp. 4545-4549
		Koichi Murakami, Tetsuo Takahashi, Tadamasa Koyanagi, Koichiro Hoh, Yoshio Komiya and Yasuo Tarui, "Thermal Analysis and Experimental Evaluation of Melting Threshold Energy of Si Thin Film Structure in Laser Annealing" Japanese Journal of Applied Physics, Vol. 21, No. 6, June 1982, pp. 879-884
EXAMINER	DATE CONSIDERED	
<i>EXAMINER: Initial if citation is considered, whether or not citation is in conformance with MPEP 609; draw a line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant</i>		